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L Number	Hits	Search Text	DB	Time stamp
1	45486	(silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:50
2	16965	(silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) near10 ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:53
5	0	156/104 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:53
6	0	156/105 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:53
16	11	438/456 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:54
17	9	438/457 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:54
18	39	438/458 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
19	53	438/459 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
20	29	438/749 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
21	32	438/750 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
22	71	438/753 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
23	47	438/756 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
24	13	438/757 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
27	0	65/406 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 08:55
28	10	65/429 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 09:13
29	5	("5858051").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 09:13

3	18	156/99 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:10
7	14	156/281 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:25
8	15	156/285 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:27
9	1	156/286 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:33
30	1	(156/286 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) not (156/285 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:33
10	6	156/308.6 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:33
11	1	156/308.8 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:34
12	7	156/309.3 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:35
14	5	156/316 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:35
15	56	438/455 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:57
31	5	(438/456 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) not (438/455 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:59
32	0	(438/457 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) not ((438/455 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/456 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 10:59

40	8	((438/750 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) not ((438/749 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/459 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/458 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/457 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/456 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/455 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))))) and bond\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 11:15
41	48	(438/753 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) not ((438/750 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/749 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/459 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/458 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/457 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/456 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide)))) or (438/455 and ((silicon or glass) and (((hno3 or hcl or h2so4 or hf) or ((nitric or sulfuric or hydrochloric or hydrofluoric) adj acid)) same ((nh4oh or koh or naoh) or ((ammonium or potassium or sodium) adj hydroxide))))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/25 11:21

-	3198	si\$1oh	USPAT; US-PGPUB	2003/07/25 08:45
-	869090	glass or silicon or silica	USPAT; US-PGPUB	2003/02/12 14:41
-	1022	((termination or funcational) near3 group	USPAT; US-PGPUB	2003/02/12 14:56
-	123317	((treating or treat or treated or treatment) near5 surface	USPAT; US-PGPUB	2003/02/12 14:42
-	26086	((treating or treat or treated or treatment) near5 surface) same (acid or acidic or base or basic)	USPAT; US-PGPUB	2003/02/12 14:43
-	1	si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group) and (((treating or treat or treated or treatment) near5 surface) same (acid or acidic or base or basic))	USPAT; US-PGPUB	2003/02/12 14:55
-	4	("4671846" "4700466" "4956204" "4962062").PN.	USPAT	2003/02/12 14:47
-	7	5451547.URPN.	USPAT	2003/02/12 14:48
-	4	si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group) and ((treating or treat or treated or treatment) near5 surface)	USPAT; US-PGPUB	2003/02/12 14:57
-	7	si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group)	USPAT; US-PGPUB	2003/02/12 14:57
-	7	(si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group)) not 5451547.URPN. or (si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group) and ((treating or treat or treated or treatment) near5 surface))	USPAT; US-PGPUB	2003/02/12 14:57
-	3	(si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group)) not (5451547.URPN. or (si\$1oh and (glass or silicon or silica) and ((termination or funcational) near3 group) and ((treating or treat or treated or treatment) near5 surface)))	USPAT; US-PGPUB	2003/02/12 15:02
-	0	(glass or silica or silicon) and (si\$2oh) and ((termination or funcational) near3 group)	USOCR	2003/02/12 15:03
-	1	(glass or silica or silicon) and (si\$2oh) and ((termination or funcational) near3 group)	EPO; JPO; DERWENT	2003/02/12 15:04
-	2	("5451547" or ("5183710")).PN.	USPAT; US-PGPUB	2003/02/12 15:04
-	5872	((hydrogen adj peroxide) or h2o2) near10 ph	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/22 17:20
-	3840	((hydrogen adj peroxide) or h2o2) near5 ph	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/22 17:21
-	3840	((hydrogen adj peroxide) or h2o2) near5 ph) and pd<=20011026	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/22 17:21
-	3120	((hydrogen adj peroxide) or h2o2) near5 ph) and @pd<=20011026	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/22 17:29
-	278	(ammonia near10 (hydrogen adj peroxide)) near10 ph	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/22 17:32
-	227	((ammonia near10 (hydrogen adj peroxide)) near10 ph) and @pd<=20011026	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/22 17:32
-	107	rossi-jessica.xa.	USPAT; US-PGPUB	2003/07/23 13:48
-	260705	(sodium hydroxide) and (silicon or quartz or glass)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 14:11

-	11222	(direct near5 bond\$3) and (silicon or silica or glass or quartz or wafer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:03
-	2157	(direct near5 bond\$3) same (silicon or silica or glass or quartz or wafer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:04
-	1280	(direct near5 bond\$3) near10 (silicon or silica or glass or quartz or wafer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:04
-	730	(direct adj bond\$3) near10 (silicon or silica or glass or quartz or wafer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:05
-	629	(direct adj bond\$3) near10 (silicon or silica or glass or quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:05
-	77	((direct adj bond\$3) near10 (silicon or silica or glass or quartz)) and ((hno3 or h2so4 or hcl) or ((nitric or sulfuric or hydrochloric) adj acid)) and (((ammonium or potassium or sodium) adj hydroxide) or (nh4oh or koh or naoh))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:11
-	3	((direct adj bond\$3) near10 (silicon or silica or glass or quartz)) same ((hno3 or h2so4 or hcl) or ((nitric or sulfuric or hydrochloric) adj acid)) same (((ammonium or potassium or sodium) adj hydroxide) or (nh4oh or koh or naoh))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 16:11
-	37	((direct adj bond\$3) near10 (silicon or silica or glass or quartz)) and (hno3 or (nitric adj acid)) and (((ammonium or potassium or sodium) adj hydroxide) or (nh4oh or koh or naoh))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 18:18
-	1	(silicon or glass or silica or wafer) and (sioh2 or sioh3 or osioh3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 18:22
-	7	(silicon or glass or silica or wafer) and ("sioh.sub."2 or "sioh.sub."3 or "osioh.sub."3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 18:37
-	24	sabia-robert.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 18:31
-	0	(silicon or glass or silica or wafer) and ("sioh.sub."2 or "sioh.sub."3 or "osioh.sub."3)	USOCR	2003/07/23 18:38
-	3100	(bond\$3 near5 (silicon or glass or quartz or silica)) and ((chemical or chemically) near10 treat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 18:43
-	360	(bond\$3 near5 (silicon or glass or quartz or silica)) same ((chemical or chemically) near10 treat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 18:44
-	117	(bond\$3 near5 (silicon or glass or quartz or silica)) near10 ((chemical or chemically) near5 treat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/23 19:15
-	14	(bond\$3 near5 (silicon or glass or quartz or silica)) near10 ((chemical or chemically) near5 treat\$4)	USOCR	2003/07/23 19:15
-	384	438/455 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:45
-	89	438/456 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:45

-	40	438/457 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:45
-	264	438/458 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:45
-	318	438/459 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	475	438/745 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	81	438/749 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	117	438/750 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	212	438/756 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	86	438/757 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	17	65/429 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	143	156/308.6 and (silicon or glass or quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:48
-	42	156/308.8 and (silicon or glass or quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	78	156/309.3 and (silicon or glass or quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:46
-	34	156/316 and (silicon or glass or quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:47
-	627	438/753 and (silicon or glass or quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:47
-	174	(438/753 and (silicon or glass or quartz)) and bond\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:47
-	188	156/99 and silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:48
-	40	156/104 and silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:48

-	7	156/105 and silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:57
-	9	65/406 and silicon and (wash\$3 or clean\$3 or cleans\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:51
-	17	(65/429 and silicon and (wash\$3 or clean\$3 or cleans\$3)) not (65/406 and silicon and (wash\$3 or clean\$3 or cleans\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:51
-	148	156/286 and silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/24 17:53